

ELECTRICAL PROPERTIES OF ZINC OXIDE (ZnO) NANORODS FOR FET
APPLICATIONS

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A report submitted in fulfillment of the requirements for the award of the degree of
Bachelor of Engineering (Hons) Electronics

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JULY 2012

ACKNOWLEDGEMENT

Bismillahirrahmanirrahim.....

First and foremost, I would like to thank to Allah S.W.T for the successful completion of my thesis. A deep gratitude goes to my supervisor, Assoc. Prof. Dr Mohamad Rusop Mahmood, for his priceless guidance and advice throughout the study. Not forgotten my co-supervisor, En Uzer Mohd Noor for his assisted in some small way at some time.

Very special thanks to my senior, Puan Salina Mohamad who leads me and support me with her guidance's in order to complete the thesis and also to my fellow course mates who had lent their hands knowingly or not.

Not forgotten to all technicians at NANO-ElecTronic Centre (NET) and NANO-SciTech Centre (IOS) for the equipment facilities and supervisions. Finally, I wish to extend my deep appreciation to my lovely parents because of their loving supports all along the way in finishing my project.

Without all the helps offered, my project would not have been this successfully. What I have learned and experienced has been invaluable to me. Thank you and May Allah S.W.T bless all of you always.

ABSTRACT

Zinc oxide (ZnO) nanorods have being growth using chemical bath deposition (CBD) method. This is done to investigate the consequences of different annealing temperature and different volume of solutions to the electrical properties of zinc oxide (ZnO) nanorods. The chemical bath deposition (CBD) method is normally used to deposit such as thin films and nanomaterials. There are many advantages using this method such as low cost technique and it is not depending on the expensive equipments. Other than that, it has low process temperature and easy to conduct the process. This study covered three processes which are preparation of Magnesium Zinc Oxide (MgZnO) solution for seed layer deposition by using sol-gel spin coating technique, preparation of Zinc Oxide (ZnO) solutions for ZnO nanorods deposition using chemical bath deposition (CBD) method and for metallization purposed, thermal electron beam evaporator has been employ to deposit alumium as a metal contact. The current-voltage (IV) characteristic has been determined by using IV probe measurement system while optical properties have been analyzed by using Perkin Elmer (LAMBDA 750) UV-VIS Spectrophotometer. The surface morphologies of ZnO nanorods were examined by using FESEM JOEL JSM-7600F while the crystallinity was determined using Rigaku Ultima IV X-Ray Diffraction (XRD). The result depicts that with different annealing temperature, it showed that sample that annealed at 500°C has the highest conductivity (low resistivity) and highest optical transmittance due to the manipulation contact resistance. Meanwhile, with the different volumes of solutions, it depicts that 50ml gave the conductive behaviour compare to the other volumes but for the transparent to visible light, 200ml gave the best result due to highest optical transmittance. As far for the concern, the molarity 0.05M does not change the density.

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CHAPTER 1

INTRODUCTION

1.1 BACKGROUND OF STUDY

According to the Moore's Law, the number of transistors, most probably field effect transistor (FET) will double every two years. As a result, the size becomes smaller around 250nm to 100nm [1] and can be below that. Due to these problems, ZnO based material has attracted attention of researchers due to its unique properties and applications including in field effect transistor (FET), transparent electronics, light emitting diodes (LED), solar cells, chemical sensor and piezoelectric devices [2].

ZnO is a semiconductor with direct band gap of 3.37eV and has large excitation binding energy of 60meV at room temperature [3-4] where it gives more efficient emission at room temperature as its unique characteristics. It also made ZnO become transparent to visible light. For instance, ZnO is suitable for photovoltaic applications because it has the highest electrical conductivity [3] and optical transmittance.

Zinc oxide (ZnO) can be grouped to transparent conducting oxide (TCO) where it can be used as transparent electrode in electronic devices. Transparent conducting oxide (TCO) is very important in thin film where ZnO can be one of the most capable materials which are necessary in high transmission and low resistivity [6].

ZnO nanorods have hexagonal wurtzite structure where oxygen atoms exist on hexagonal sites while zinc atoms are in tetrahedral sites. Under thermal equilibrium,